

Response and transit times in quantum-well structures

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The response of a biased double-barrier quantum well to a small ac voltage with characteristic time τ_{resp} and the transit or dwell time τ_{trans} are calculated using nonequilibrium Green's-function techniques. The tunneling process is shown to be predominantly sequential for an $\text{In}_x\text{Ga}_{1-x}\text{As}/\text{In}_y\text{Al}_{1-y}\text{As}$ structure due to only well alloy scattering treated in the coherent-potential approximation. The magnitudes of τ_{resp} and τ_{trans} are in close agreement and about the same for either sequential or coherent tunneling.

This paper introduces a technically significant time for tunneling in a double-barrier quantum well (DBQW), viewed as a response time τ_{resp} to a weak oscillatory field applied to a biased structure along any point of its current-voltage (I - V) characteristic. Its magnitude is calculated using nonequilibrium Green's-function techniques. It is shown to be nearly the same as the transit time τ_{trans} defined and measured by Chemla and co-workers.^{1,2} Furthermore, the paper demonstrates that sequential tunneling strongly dominates resonant tunneling^{3,4} as a result only of weak III-V alloy scattering, for example, in the well of a lattice-matched $\text{In}_x\text{Ga}_{1-x}\text{As}/\text{In}_y\text{Al}_{1-y}\text{As}$ structure described within the coherent-potential approximation (CPA).^{5,6} The magnitude of τ_{resp} or τ_{trans} , however, is only weakly dependent on the details of the tunneling process.

Aside from their intrinsic physical interest, these results are important since negative-differential-resistance diodes or DBQW are prototypical circuit components in cellular automata in which each cell is required to have high-frequency response and to be "locally interacting," i.e., decoupled from all but its nearest neighbors. Decoupling can be achieved if wave-function coherence between adjacent cells is eliminated. The dominance of sequential tunneling processes, which eliminate coherence, is therefore important.

Specifically, τ_{resp}^{-1} is defined as the frequency, ω_{resp} , for which the imaginary part of the conductivity $\sigma(\omega)$ is maximum. This response time, which is appropriate for high-frequency applications, is physically different from the transit time τ_{trans} defined as the ratio of the charge density in the well to the current density, ρ_w/j_{dc} , at arbitrary bias.

The model of a biased symmetric DBQW to be used in this analysis is shown in Fig. 1. The well having width d_w is surrounded by two barriers having height Λ_S and width d_S where $S=L$ (left) or R (right). The Fermi levels μ_L and μ_R in the leads represent the effect of charge accumulation in L and depletion in R . The semiconductor alloys ($\text{In}_x\text{Ga}_{1-x}\text{As}$) in the L, R and well (W) regions are assumed to be the same, as are those of the barriers ($\text{In}_y\text{Al}_{1-y}\text{As}$). The potential drop across the structure is modeled by a stepwise constant potential energy having values $\Phi_L = eV_{\text{dc}}$, where V_{dc} is the voltage drop, $\Phi_w = \frac{1}{2}\Phi_L$ for a symmetric DBQW, and $\Phi_R = 0$. The

tunneling matrix element through the barrier, h_{SW} , is given within the WKB approximation. The well is assumed to contain only one resonant level E_0 in the absence of alloying effects. E_0 represents the edge of a two-dimensional conduction band (CB) with energy $\Phi_w + E_0 + \epsilon_{k_{\parallel}}$, where k_{\parallel} are associated with the two-dimensional continuum perpendicular to the growth axis and $\epsilon_{k_{\parallel}} = \hbar^2 k_{\parallel}^2 / 2m^*$.

The Hamiltonian is given as a sum of terms H_S^0 unperturbed by barrier tunneling and well scattering and others, H_{SW}^{tun} and H_w^{scat} , describing the remaining effects. Explicitly, in terms of appropriately labeled creation and annihilation operators,

$$H_S^0 = \begin{cases} \sum_{\mathbf{k}} (\epsilon_{\mathbf{k}} + \Phi_S) c_{S\mathbf{k}}^\dagger c_{S\mathbf{k}}, & S = L, R \\ \sum_{k_{\parallel}} (E_0 + \epsilon_{k_{\parallel}} + \Phi_w) c_{Wk_{\parallel}}^\dagger c_{Wk_{\parallel}}, & S = W, \end{cases} \quad (1)$$

where $\mathbf{k} = (k_{\parallel}, k_z)$ refers to the L and R regions and

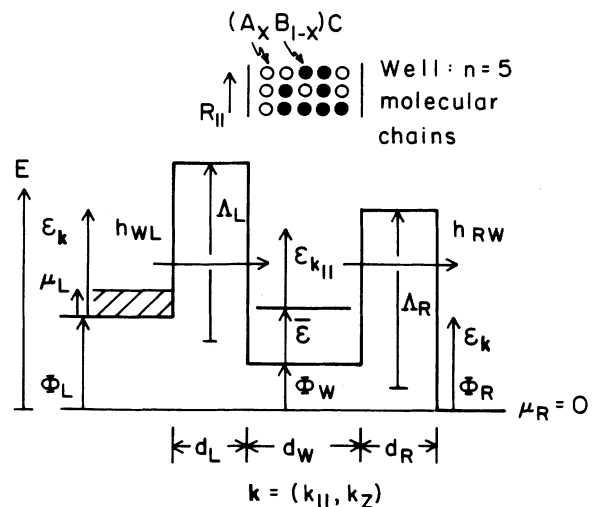


FIG. 1. Model of biased DBQW structure. Barrier and well dimensions defined in text; alloy well resonance level $\bar{\epsilon}$; Fermi level μ_L, μ_R ; tunneling amplitudes h_{WL}, h_{RW} . Inset: Arrangement of random molecular chains having $n=5$ AC (open) or BC (closed) molecules for $(A_x B_{1-x})C$ well alloy.

$\varepsilon_{\mathbf{k}} = \hbar^2 \mathbf{k}^2 / 2m^*$. Further

$$H_{WS}^{\text{tun}} = \sum_{k_z, k_{\parallel}} (h_{WS} c_{Wk_{\parallel}}^{\dagger} c_{Sk} + \text{H.c.}) \quad (2)$$

and

$$H_W^{\text{scat}} = \sum_{R_{\parallel}} (\varepsilon_{R_{\parallel}} - E_0) c_{WR_{\parallel}}^{\dagger} c_{WR_{\parallel}} \quad (3)$$

in a representation using two-dimensional Wannier creation operators $c_{WR_{\parallel}}^{\dagger}$. As indicated in the inset of Fig. 1, a row of atoms along the growth direction is visualized as an n -membered molecular chain consisting of randomly disordered AC and BC molecules constituting the $(A_x B_{1-x})C$ alloy. The position of each chain is defined by a value of R_{\parallel} as indicated in Fig. 1. The resulting two-dimensional alloy scattering associated with each of the randomly distributed chains is the only scattering effect to be considered here. Even though scattering is weak for III-V alloys, it causes tunneling to be largely sequential. The scattering potential due to the configuration-dependent energy

$$\varepsilon_{R_{\parallel}} = \bar{\varepsilon} + \sum_i |\phi(z_i)|^2 (\varepsilon_i - \bar{\varepsilon}) \quad (4)$$

for each chain, where $i = 1, 2, \dots, n$ labels the sequence of AC and BC molecules with on-site electronic energies $\varepsilon_A, \varepsilon_B$, respectively, is much weaker than the confinement kinetic energy E_0 . Here $\bar{\varepsilon} = x\varepsilon_A + (1-x)\varepsilon_B$ denotes the virtual crystal CB edge; $\bar{\varepsilon}$ replaces E_0 in the alloy case; $\varepsilon_A - \varepsilon_B$ is the CB offset between the AC and BC crystals.

Equation (4) gives the chain energies to first order in the scattering. $\phi(z_i)$ is the normalized envelope function along the growth axis. The $\varepsilon_{R_{\parallel}}$ are assumed to have a Gaussian distribution with probability $(\Delta\sqrt{2\pi})^{-1} \exp[-(\varepsilon_{R_{\parallel}} - \bar{\varepsilon})^2 / 2\Delta^2]$ and a variance

$$\Delta^2 = x(1-x)(\varepsilon_A - \varepsilon_B)^2 \left[(d_W/n) \int_W dz |\phi(z)|^4 \right],$$

where the integral extends over the well width d_W and has the value $3/(2d_W)$ for deep wells. The CPA description of Gaussian disorder has been considered previously.⁷

A nonequilibrium Green's-function formalism must be used to calculate the current since inelastic-scattering processes are neglected here, and are insufficient to achieve equilibrium in the well region at low T in any case. The advanced and retarded Green's functions G^a , G^r , and also $G^<$ are related by Dyson's equations.^{8,9} The quantities of particular physical interest obtained from a solution of these equations are the matrix elements of the configuration averaged well Green's functions

$$\begin{aligned} G^r(Wk_{\parallel}, Wk'_{\parallel}; E) &= \delta_{k_{\parallel} k'_{\parallel}} [E - (\bar{\varepsilon} + \varepsilon_{k_{\parallel}} + \Phi_W) \\ &\quad - \Sigma_L(k_{\parallel}; E) - \Sigma_R(k_{\parallel}; E) \\ &\quad - \Sigma_{\text{CPA}}(E)]^{-1} \end{aligned} \quad (5)$$

and

$$\begin{aligned} G^<(Wk_{\parallel}, Wk_{\parallel}; E) &= -\phi_W(E) [G^r(Wk_{\parallel}, Wk_{\parallel}; E) \\ &\quad - G^a(Wk_{\parallel}, Wk_{\parallel}; E)] \\ &= 2\pi i \phi_W(E) A(k_{\parallel}, E). \end{aligned} \quad (6)$$

In Eq. (5), Σ_L and Σ_R are the self-energies associated with tunneling processes out of the well W to L and R , respectively, and Σ_{CPA} is associated with disorder scattering in the well. We shall assume the self-energy shift to be absorbed in $\bar{\varepsilon}$. The remaining part,

$$\begin{aligned} i \text{Im}[\Sigma_{S=L,R}] &= -i\pi |h_{WS}|^2 \sum_{k_z} \delta(E - \varepsilon_{\mathbf{k}} - \Phi_S) \\ &\equiv -\frac{1}{2} i \Gamma_S \end{aligned} \quad (7)$$

and $i \text{Im}[\Sigma_{\text{CPA}}] = -\frac{1}{2} i \Gamma_{\text{scat}}$ describes the broadening due to tunneling and scattering, respectively. Γ_S is the resonant level width associated with the escape time through the barrier at side $S=L, R$. Γ_{CPA} (not defined explicitly here) is the energy-dependent level width associated with scattering. It is obtained from a numerical solution of the CPA equations. The tunneling process through the DBQW is seen to be largely coherent if $\Gamma_{\text{CPA}} \ll \Gamma_L, \Gamma_R$ and sequential in the opposite limit.

Equation (6) contains $\phi_W(E)$, the nonequilibrium distribution of electrons in the well. This form⁹ is analogous to $G_0^<(S\mathbf{k}, S\mathbf{k}; E)$, the unperturbed function in the L and R regions, in which $\phi_W(E)$ is replaced by the equilibrium Fermi distributions $f_L(E - \Phi_L)$ and $f_R(E)$.¹⁰ $A(k_{\parallel}, E)$ is the spectral density associated with the state k_{\parallel} .

The dc current density (per unit area) j_{dc} is obtained by calculating the $S \rightarrow W$ current density $j_{S \rightarrow W} = 2e(\partial/\partial t) \hat{N}_S$ where $\hat{N}_S = \sum_{\mathbf{k}} c_{kS}^{\dagger} c_{kS}$ and expressing the result in terms of the Green's functions. The well distribution is obtained from current conservation $j_{L \rightarrow W} = j_{W \rightarrow R}$:

$$\phi_W(E) = [\Gamma_L f_L(E - \Phi_L) + \Gamma_R f_R(E)] / (\Gamma_L + \Gamma_R). \quad (8)$$

The remarkably simple formal result is

$$j_{\text{dc}} = \frac{2e}{\hbar} \int_{-\infty}^{\infty} dE \frac{\Gamma_L \Gamma_R}{\Gamma_L + \Gamma_R} g_W(E) [f_L(E - \Phi_L) - f_R(E)], \quad (9)$$

where $g_W(E) = \int A(k_{\parallel}, E) d^2 k_{\parallel} / (2\pi)^2$ is the two-dimensional well density of states. We note that the form of Eqs. (8) and (9) is that expected when the tunneling is purely sequential. The same formal result is obtained by considering the purely coherent tunneling limit obtained by setting $\Sigma_{\text{CPA}} = 0$. The bias dependence of this nonlinear I - V dependence is indicated explicitly. Except for its dependence on V_{dc} , the Γ_S may be assumed constant since the resonance width is < 1 meV, except when V_{dc} is such that the well CB edge coincides energetically with that of the CB on the left (in the negative-resistance region).

The level broadening associated with tunneling and scattering is contained entirely in $g_W(E)$. The spectral densities with and without scattering, $A(k_{\parallel} = 0, E)$, are compared in Fig. 2 for the state at the well CB edge when

it lies just above (0.2 meV) the left CB edge in the absence of scattering for a lattice matched $\text{In}_{0.53}\text{Ga}_{0.47}\text{As}/\text{In}_{0.52}\text{Al}_{0.48}\text{As}$ DBQW with $d_W=45$ Å and $d_L=d_R=56$ Å. This illustrative example corresponds to sample *A* of Ref. 1 which was measured at 10 K. We set $\mu_L=50$ meV. Scattering effects shift the CB edge by $\text{Re}[\Sigma_{\text{CPA}}]$ as indicated. To permit comparison, the Lorentzian resonant peak associated with tunneling has been shifted by $\text{Re}[\Sigma_{\text{CPA}}]$. The shape of $A(0,E)$ including scattering is strongly asymmetric. This behavior results from the Gaussian distribution of states that blur the CB edge: The high-energy tail results from the increasing density of state available for scattering; the sharp cutoff at low energies is primarily associated with the energy dependence of $\text{Re}[\Sigma_{\text{CPA}}]$. Both widths are small compared to eV_{dc} . Since the f_S and Γ_S in Eq. (9) are weakly dependent on energy when eV_{dc} lies well within the Ohmic (positive-differential-resistance) region, the energy integral reduces to $\int dE g_W(E + \Phi_W)$ and is the same for all reasonable alloy scattering strengths. As a result j_{dc} in these regions is unaffected by scattering,¹¹ and will be the same regardless of whether the transport is coherent or sequential. Thus, neither τ_{resp} nor τ_{trans} will be appreciably affected by the tunneling

mechanisms. Note also that I - V measurements cannot be used to distinguish between coherent and sequential tunneling.

For a given V_{dc} , the factor $\Gamma_L \Gamma_R / (\Gamma_L + \Gamma_R)$ may be removed from the integral in Eq. (9). Similarly, the contribution to the current from unscattered electrons can be shown to be $j_{\text{dc}} \propto \Gamma_L \Gamma_R / (\Gamma_L + \Gamma_R + \Gamma_{\text{scat}})$. The fraction of coherent tunneling is thus $(\Gamma_L + \Gamma_R) / (\Gamma_L + \Gamma_R + \Gamma_{\text{scat}})$. Its value is about 1% for sample *A* of Ref. 1.

The transit time, $\tau_{\text{trans}} = \rho_W / j_{\text{dc}}$, where

$$\rho_W = \int_{-\infty}^{\infty} dE \phi_W(E) g_W(E) \quad (10)$$

is the charge density in the well, was measured by Chemla and co-workers¹ using differential absorption spectroscopy. Figure 3 compares the measured and calculated τ_{trans} in the Ohmic region as a function of current density for sample *A* of Ref. 1. The range of current densities for the experimental points is larger than that for the calculations because the experimental maximum current density exceeds the calculated value. The factor of 3–4 difference is reasonable in view of the approximations inherent in the model, the neglect of other scattering effects,¹² and the exponential dependence of h_{WS} on input parameters.

τ_{trans} may be estimated simply when $\bar{\epsilon}$ is aligned with filled states on the left and empty states on the right. Equations (8)–(10) yield $\tau_{\text{trans}} \sim \hbar / \Gamma_R \approx 75$ ps in the present case when $j_{\text{dc}} = 100$ A/cm², in agreement with the physical expectation that the transit time is controlled by the effective height of the right barrier.

The importance of the frequency response of a DBQW operating as a negative-differential-resistance diode characterized by the response time τ_{resp} has already been noted. Operationally, the appropriately biased DBQW,

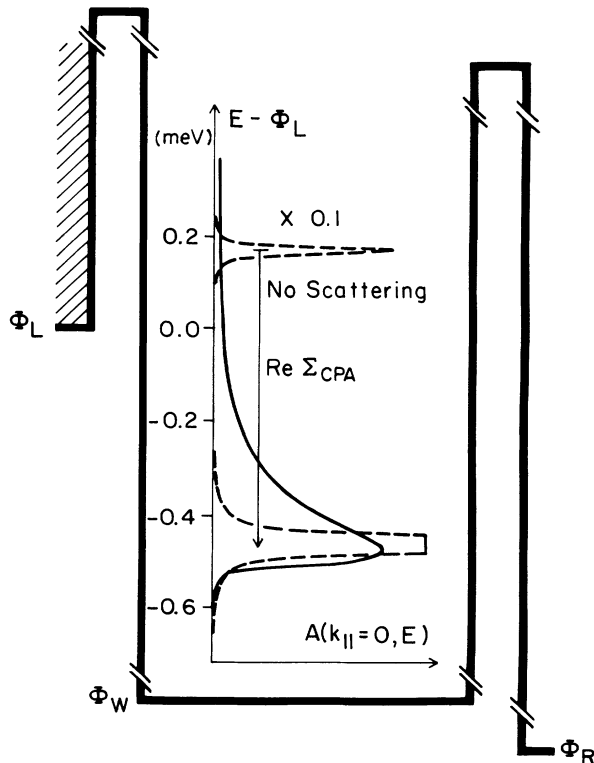


FIG. 2. Spectral density $A(k=0, E)$ for biased DBQW at far end of negative-differential-resistance regime with (solid curve) and without (dashed curve) alloy scattering. Resonance is sharper and located in positive-differential-resistance region for the case of well lifetime broadening alone (upper dashed curve; multiplied by 0.1). Shift by $\text{Re}[\Sigma_{\text{CPA}}]$ and scale change permits comparison between line shapes. DBQW is indicated schematically. Dashed region on left occupied by electrons.

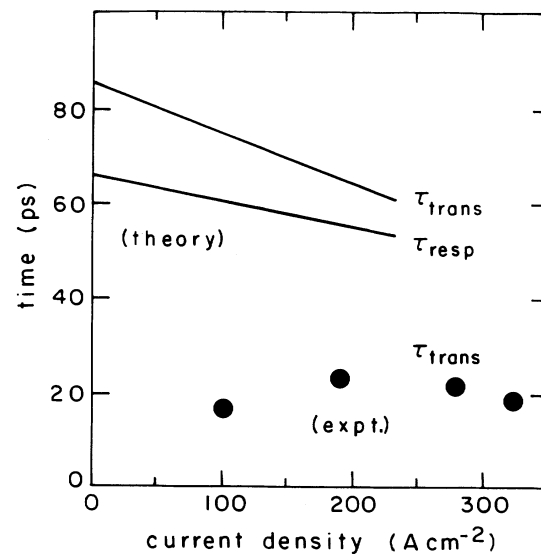


FIG. 3. Theoretical response and transit times vs current density compared with experiment, sample *A*, Ref. 1, in positive-differential-resistance region.

acted upon by an additional small ac field having frequency ω with Hamiltonian

$$H_{\text{ac}} = \frac{1}{2} e V_{\text{ac}} (\hat{N}_L - \hat{N}_R) e^{-i\omega t}$$

responds linearly to that field. For frequencies $\omega > \omega_{\text{resp}}$, as defined above, the current is no longer able to follow H_{ac} without phase lag. The upper frequency limit of de-

vice operation is thus given by $\omega_{\text{resp}} = \tau_{\text{resp}}^{-1}$. (The frequency limit is depressed due to circuit capacitance effects and other scattering mechanisms.)

The derivation of $\sigma(\omega)$ is lengthy, since a Bethe-Salpeter equation must be solved to include vertex corrections properly.¹³ The result, valid for the Ohmic region in which the energy dependence of the Γ_S can be neglected, is

$$\sigma(\omega) = \frac{e^2}{2\hbar^2\omega} \int_{-\infty}^{\infty} dE g_W(E; \omega) \frac{(\hbar\omega + 2i\Gamma_R)\Gamma_L(\Delta f_L) + (\hbar\omega + 2i\Gamma_L)\Gamma_R(\Delta f_R)}{\hbar\omega + i(\Gamma_L + \Gamma_R)}, \quad (11)$$

where

$$g_W(E; \omega) = (-2\pi i)^{-1} [F_{\text{CPA}}^r(E + \hbar\omega) - F_{\text{CPA}}^a(E)],$$

$$F_{\text{CPA}}^{r(a)} = \langle 0 | G_{\text{CPA}}^{r(a)}(E) | 0 \rangle,$$

the single-chain diagonal matrix element of the CPA retarded (advanced) Green's function, and $\Delta f_S = f_S(E + \hbar\omega - \Phi_S) - f_S(E - \Phi_S)$ ($S = L, R$). Note that $g_W(E; 0) = g_W(E)$, the well density of states in Eq. (9), and that $\sigma(0) = dj_{\text{dc}}/dV_{\text{dc}}$ at a given V_{dc} in the present case. The applied dc voltage remains even when V_{ac} , which is much smaller than V_{dc} , has vanishing frequency.

The results for τ_{resp} are also shown in Fig. 3. Even though the physical ingredients in the definitions of τ_{trans} and τ_{resp} are quite different, the numerical values are seen

to be in remarkably close agreement. Calculations for a typical current of $j_{\text{dc}} = 100$ A/cm² in the *negative-differential-resistance* region (not indicated in Fig. 3) show that τ_{trans} and τ_{resp} have values about 60 ps and differ by only 7 ps, as in the Ohmic region. This result confirms that the experimentally accessible time defined and measured in Ref. 1 is, in fact, useful in device applications of current interest.

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